## SCOPE OF CLAIMED INVENTION:

- A semiconductor device characterized in comprising:
- a first semiconductor chip mounted on a substrate;
- a second semiconductor chip mounted on the first semiconductor chip, the second semiconductor chip being larger than the first semiconductor chip;

a base member that is disposed between the second semiconductor chip and the substrate; and

a connection member disposed below the substrate,

wherein the second semiconductor chip is supported by the base

- 2. A semiconductor device characterized in comprising:
- a first semiconductor chip mounted on a substrate;
- a second semiconductor chip mounted on the first semiconductor chip, the second semiconductor chip being larger than the first semiconductor chip;
- a filler layer that is provided between the second semiconductor chip and the substrate; and
  - a connection member disposed below the substrate,

wherein the second semiconductor chip is supported by the filler layer.

 ${\bf 3.} \qquad {\bf A} \ {\bf method} \ {\bf for} \ {\bf manufacturing} \ {\bf a} \ {\bf semiconductor} \ {\bf device}, \ {\bf the} \\ {\bf method} \ {\bf characterized} \ {\bf in} \ {\bf comprising} \ {\bf the} \ {\bf steps} \ {\bf of:} \\$ 

mounting a first semiconductor chip on a substrate;

mounting a base member outside the first semiconductor chip on the substrate; and

mounting a second semiconductor chip that is larger than the first semiconductor chip on the first semiconductor chip, in a manner that the second semiconductor chip is supported by the base member. 4. A method for manufacturing a semiconductor device, the method characterized in comprising the steps of:

mounting a first semiconductor chip on a substrate,

mounting a second semiconductor chip that is larger than the first semiconductor chip on the first semiconductor chip; and

providing a filler layer in a manner to support the second semiconductor chip.